

Title (en)

A machine for the continuous plating and embossing of hides and the like

Title (de)

Maschine zum kontinuierlichen Plattieren und Prägen von Häuten und dergleichen

Title (fr)

Machine pour le placage et l'estampage continu des peaux ou similaires

Publication

EP 1024202 A2 20000802 (EN)

Application

EP 00100882 A 20000118

Priority

IT VI990013 A 19990127

Abstract (en)

The invention provides a machine (1) for the continuous plating and embossing of hides and the like, particularly suitable for processing hides tanned with the ecological system, which uses products that can be diluted in water and that require a reaction time to reticulate, in order to affix the plating and embossing action on the surface thereof, significantly greater than the times required by hides tanned with chemical solvents. The machine (1) is characterised by the fact that the plating and embossing action of the hide (4) is performed by winding and pressing it on an operating cylinder (2) by means of a belt (3) under tension, also partially wound on said cylinder (2) and placed externally thereto. <IMAGE>

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Cited by

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